Supporting Information:

## Facile fabrication and optoelectronic properties of platinum

## octaethylporphyrin microsheets

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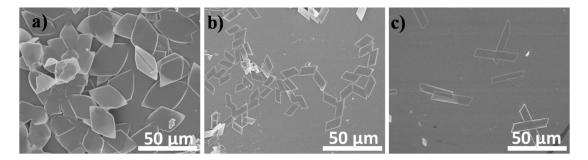
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## **Experimental section**

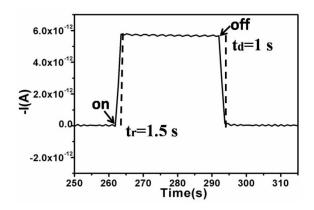
In a typical experiment, PtOEP powder (99%, Aldrich) was dissolved in Chloroform at a concentration of 2 mg/ml. The PtOEP chloroform solution was slowly injected into propylene glycol methyl ether acetate (PGMEA). The volume ratio of V<sub>chloroform</sub>/V<sub>PGMEA</sub> was 3:1. A drop of PtOEP solution was then directly dropped onto the heavily-doped clean Si substrate. After the solvent evaporation, the microsheets of PtOEP were formed. To remove the solvent thoroughly, the microsheets were post-annealed at 150 °C for 30 min. The morphology and crystalline structures were then characterized by scanning electron microscopy (SEM. Quanta 400 FEG), transmission electron microscopy (TEM, Tecnai G2 20 diffraction Bruker D8 Advance S-Twin), X-ray (XRD, X-Ray Diffractometer), Fourier-transform infrared (FTIR, Thermo Fisher Scientific FTIR 6700), atomic force microscope (Veeco), confocal laser Raman microscope (JY HR800), and fluorescence microscope (Leica DM 4000M).

The photodetectors were constructed in bottom-connected configuration. The finger

electrodes with the length of 200  $\mu$ m, the width of 10  $\mu$ m and the distance of 10  $\mu$ m, were fabricated by the photolithography and electron beam deposition of Au on the SiO<sub>2</sub>/Si substrate. The 5  $\mu$ l PtOEP solution (0.5 mg/ml, the mixed solvent volume ratio of V<sub>chloroform</sub>:V<sub>PGMEA</sub> was 3:1 ) was directly deposited on 5mm×5mm the Au electrodes deposited SiO<sub>2</sub>/Si substrate. The solvent was allowed to evaporate in air. To remove the solvent thoroughly and enhance the contact the nanowire and the Au electrodes, the device was also post-annealed at 150 °C for 30 min. Current-voltage characteristics of the devices were recorded with Keithley 4200 SCS and RF Probe Station (PE-4RF) probe station in a clean and shielded box at room temperature. A Xenon lamp was used as the white light source with different intensity. All measurements were carried out at ambient conditions.



**Figure S1**. SEM images of PtOEP microsheets fabricated by using different volume ratio of chloroform solution and PGMEA: (a) 5:1; (b) 3:1, (c) 1:1;



**Figure S2.** The rise time  $(t_r)$  and the decay time  $(t_d)$  of the device based on PtOEP microsheet.